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UNITED STATES DEPARTMENT OF COMMERCE United States Patent and Trademark Office Address: COMMISSIONER OF PATENTS AND TRADEMARKS Washington, D.C. 20231 www.uspto.gov FIRST NAMED INVENTOR APPLICATION NO. FILING DATE ATTORNEY DOCKET NO. CONFIRMATION NO. 04/03/2000 Kyeong Jin Kim 8733.20102 4200 09/541,426 7590 03/11/2002 Long Aldridge & Norman LLP **EXAMINER** 701 Pennsylvania Avenue NW NGUYEN, DUNG T Washington, DC 20004 ART UNIT PAPER NUMBER

> 2871 DATE MAILED: 03/11/2002

Please find below and/or attached an Office communication concerning this application or proceeding.

Office Action Summary

Application No. 09/541,426

Applicant(s)

Kim et al.

Examiner

Dung Nguyen

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	The MAILING DATE of this communication appears	on the cover sheet with the correspondence address
A SHO THE N	For Reply ORTENED STATUTORY PERIOD FOR REPLY IS SET MAILING DATE OF THIS COMMUNICATION. Usions of time may be available under the provisions of 37 Cl Uter SIX (6) MONTHS from the mailing date of this communic	FR 1.136 (a). In no event, however, may a reply be timely filed
- If the be - If NO co - Failur - Any r	period for reply specified above is less than thirty (30) days considered timely. period for reply is specified above, the maximum statutory immunication. The to reply within the set or extended period for reply will, by	and an areply within the statutory minimum of thirty (30) days will be be a reply within the statutory minimum of thirty (30) days will be be a replication to become ABANDONED (35 U.S.C. § 133). It is mailing date of this communication, even if timely filed, may reduce any
Status	,	
1) 💢	Responsive to communication(s) filed on Feb 6, 20	02
2a) 🗌	This action is FINAL . 2b) 💢 This act	ion is non-final.
3) 🗆	Since this application is in condition for allowance except for formal matters, prosecution as to the merits is closed in accordance with the practice under <i>Ex parte Quayle</i> , 1935 C.D. 11; 453 O.G. 213.	
Disposi	tion of Claims	
4) 💢	Claim(s) <u>1-56</u>	is/are pending in the application.
4	a) Of the above, claim(s)	is/are withdrawn from consideration.
5) 🗆	Claim(s)	is/are allowed.
6) 💢	Claim(s) 1-56	is/are rejected.
7) 🗆	Claim(s)	is/are objected to.
8) 🗆	Claims	are subject to restriction and/or election requirement.
Applica	tion Papers	
9) 🗆	The specification is objected to by the Examiner.	
10)	The drawing(s) filed on is/are	objected to by the Examiner.
11)	The proposed drawing correction filed on	is: a) □ approved b) □ disapproved.
12)	The oath or declaration is objected to by the Exam	iner.
13)□	under 35 U.S.C. § 119 Acknowledgement is made of a claim for foreign p \Box All b) \Box Some* c) \Box None of:	riority under 35 U.S.C. § 119(a)-(d).
	1. \square Certified copies of the priority documents have	ve been received.
	2. \square Certified copies of the priority documents have	re been received in Application No
	 Copies of the certified copies of the priority d application from the International Bure ee the attached detailed Office action for a list of th 	
14)	Acknowledgement is made of a claim for domestic	
Attachm	ent(s)	
	otice of References Cited (PTO-892)	18) Interview Summary (PTO-413) Paper No(s).
	otice of Draftsperson's Patent Drawing Review (PTO-948)	19) Notice of Informal Patent Application (PTO-152)
17) 🔲 fn	formation Disclosure Statement(s) (PTO-1449) Paper No(s).	20) Other:

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DETAILED ACTION

Applicant's request for reconsideration of the finality of the rejection of the last Office action dated 11/06/2001 is persuasive and; therefore, the finality of that action is withdrawn.

Applicant's arguments dated 02/06/2002 have been considered but are moot in view of the new grounds of rejection.

Claim Rejections - 35 USC § 103

- 1. The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:
 - (a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negatived by the manner in which the invention was made.
- 2. Claims 1-5, 7-22, 24, 26-33, 35-50, 52 and 54-56 are rejected under 35 U.S.C. 103(a) as being anticipated by Koma, US Patent No. 5,608,556, in view of Auman et al., US Patent No. 6,139,926.

Regarding claims 1-5, 7-22, 24, 26, 29-33, 35-50, 52 and 54, Koma's figures 3, 8 and 10 disclose a multi-domain liquid crystal display (LCD) device comprising:

- a first substrates (10) and a second substrate (30) facing each other;
- a homeotropic liquid crystal layer (41);
- a plurality of gate bus lines (12), a plurality of data bus lines (20), a plurality of TFTs (15) including a gate insulator (13), a passivation layer (21), and a pixel electrode (17);

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• an electric field inducing window (control window 33b) in the pixel electrode;

• an alignment layer (23) having a pretilt angle substantially 1° (respect to normal line).

Although Koma does not disclose a photo alignment forming on at least one of the first and second substrates, Koma does disclose that the alignment layer is formed by polyimide which can be a photoalignment as shown by Auman et al. (see abstract). Therefore, it would have been obvious to one of ordinary skill in the art at the time of the invention was made to provide the polyimide photo alignment film of Auman et al. by using a photo-aligning treatment such as exposing the alignment film to UV light in order to avoid electrostatic discharge caused by rubbing process (col. 2, ln. 48). Furthermore, it would have been obvious to one having ordinary skill in the art at the time the invention was made to use an alignment material selected from the group of PVCN, PSCN and CelCn based compound, since it has been held to be within the general skill of a worker in the art to select a known material on the basis of its suitability for the intended use as a matter of obvious design choice. *In re Leshin, 125 USPQ 416*.

Regarding claims 27-28 and 55-56, the modification to Koma does not disclose a negative uniaxial film or a negative biaxial film disposed on at least one substrate. One of ordinary skill in the art would have realized the desire to dispose a negative uniaxial film or a negative biaxial film on at least one substrate of an LCD device for compensating the phase difference of the direction according to viewing-angle. Therefore, it would have been obvious to one of ordinary skill in the art at the time of the invention to form a negative uniaxial film or a negative biaxial film on at least one substrate of an LCD device because it is a common practice

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in the art to improve contrast and/or reduce inversion, often in the same viewing areas in an LCD device.

3. Claims 6 and 34 are rejected under 35 U.S.C. 103(a) as being unpatentable over Koma, US Patent No. 5,608,556, in view of Auman et al., US Patent No. 6,139,926, further in view of Applicant's submitted prior art, Koma et al..

Regarding claims 6 and 34, although Koma ('556) does not disclose the "L-shaped" TFT in the LCD device, it would have been obvious to one skill in the art to form a TFT having a "L-shaped" as evidence from the Applicant's submitted prior art, Koma et al. figure 5 since it is well known in the art in order to increase an aperture ratio of an LCD device.

4. Claims 23 and 25 are rejected under 35 U.S.C. 103(a) as being unpatentable over Koma, US Patent No. 5,608,556, in view of Auman et al., US Patent No. 6,139,926, further in view of Bos et al., US Patent No. 6,141,074.

Regarding the above claims, the modification to Koma discloses the claimed invention as described above except for the liquid crystal layer which has a positive or negative dielectric anisotropy and chiral dopants. Bos et al. do disclose a multi-domain LCD which can be formed with a positive or negative dielectric anisotropy liquid crystal layer (see Summary of the Invention). Therefore, it would have been obvious to one of ordinary skill in the art at the time of the invention was made to form a liquid crystal layer having a positive dielectric anisotropy or negative dielectric anisotropy because the use of one conventional material over another merely depends on the desire of the manufacturer (i.e., homogeneous or homeotropic alignment) and/or

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the availability and practicality of the material for the chosen manufacturing process (see Summary of the Invention).

5. Claims 51 and 53 are rejected under 35 U.S.C. 103(a) as being unpatentable over Koma, US Patent No. 5,608,556, in view of Auman et al., US Patent No. 6,139,926, further in view of Van De Witte, US Patent No. 5,936,692.

Regarding the above claims, Koma discloses the claimed invention as described above except for the liquid crystal layer including chiral dopants. However, Van De Witte does disclose that an LCD can be included a chiral dopant (col. 2, ln. 21). Therefore, it would have been obvious to one of ordinary skill in the art at the time of the invention was made to form a chiral dopant in an LCD device as shown by Van de Witte since it is a common practice in the art to obtain a uniform twist sense (col. 2, ln. 24).

Conclusion

6. The prior art made of record and not relied upon is considered pertinent to applicant's disclosure.

Suzuki et al. (US 6,256,082), Matsuyama et al. (US 6,300,996) disclose an LCD with a control window forming on a pixel electrode.

Auman et al. (US 6,139,926), Kwon et al. (US 6,312,875) disclose an LCD having a photo-aligned alignment film.

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Any inquiry concerning this communication or earlier communications from the examiner should be directed to Examiner Dung Nguyen whose telephone number is (703) 305-0423. The fax phone number for this Group is (703) 746-7730.

Any information of a general nature or relating to the status of this application should be directed to the group receptionist whose telephone number is (703) 308-0956.

DN 03/05/2002

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